

11017 U.S. PTO
10/084828



U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10084828	FILING DATE 02/28/2002	CLASS 430	SUBCLASS 270.1	GAU 1752	EXAMINER CLARKE
**APPLICANTS: Harada Yuji; Watanabe Jun; Hatakeyama Jun; Kawai Yoshio; Sasago Masaru; Endo Masayuki; Kishimura Shinji; Ootani Michitaka; Miyazawa Satoru; Tsutsumi Kentaro; Maeda Kazuhiko;					
**CONTINUING DATA VERIFIED:					
** FOREIGN APPLICATIONS VERIFIED: JAPAN 2001-053664 02/28/2001 JAPAN 2001-053669 02/28/2001					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no		35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO KOJIM-449	
Verified and Acknowledged Examiners's initials					
TITLE : Polymers, resist compositions and patterning process					

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Primary Examiner	
		Application Examiner	
PREPARED FOR ISSUE		WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.	

FILED WITH:

☐ DISK (CRF)

☐ CD-ROM

(Attached in pocket on right inside flap)

BEST AVAILABLE COPY